





AMENDMENT UNDER 37 C.F.R. § 1.116 EXPEDITED PROCEDURE GROUP 2826 PATENT APPLICATION

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q77191

Koichi OHTO, et al.

Appln. No.: 10/650,193

Group Art Unit: 2826

Confirmation No.: 6245

Examiner: Alexander O. WILLIAMS

Filed: August 28, 2003

For:

SEMICONDUCTOR DEVICE HAVING SILICON-DIFFUSED METAL WIRING

LAYER AND ITS MANUFACTURING METHOD

## AMENDMENT UNDER 37 C.F.R. § 1.116

## MAIL STOP AF

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated May 20, 2005, please amend the above-identified application as follows on the accompanying pages. A Petition for a three month extension of time is being concurrently filed making a response timely by November 20, 2005. A Notice of Appeal is also being concurrently filed herewith.

## **TABLE OF CONTENTS**

AMENDMENTS TO THE SPECIFICATION	
A APAIDA ADAMO TO THE OLABAC	
AMENDMENTS TO THE CLAIMS	٠۲
REMARKS	.11